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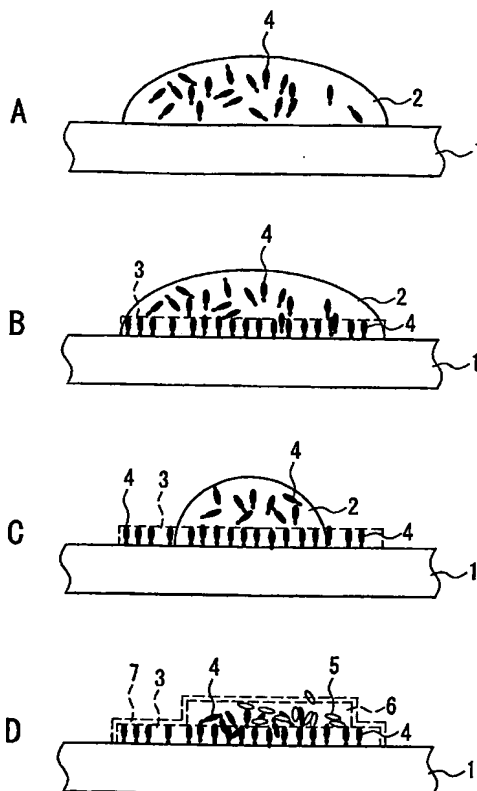
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(54) Title: DISCHARGING SOLUTION, METHOD FOR PRODUCING PATTERNS AND METHOD FOR PRODUCING AN ELECTRONIC DEVICE USING THE DISCHARGING SOLUTION, AND ELECTRONIC DEVICE



(57) Abstract: A discharging solution capable of forming patterns with spreading suppressed on the surface of a base without previously forming a complementary repellent region on the surface of the base, a method for forming the patterns, and the like are provided. More specifically, a discharging solution and the like for forming patterns with spreading suppressed on the surface of a base using, for example, an ink-jet method is provided. The discharging solution for forming patterns on the surface of a base include organic molecules having fluoroalkyl chains as a first pattern formation material, and has a surface tension of 20 dyne/cm or more.

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